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Binder polymer influence on the electrical and UV response of organic field-effect transistors†

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The use of blends of small molecule organic semiconductors (OSCs) with insulating binding polymers has been shown to be a promising route to facilitate the processing of OSCs over large areas using printing techniques. Here we fabricated organic field-effect transistors (OFETs) and phototransistors using the benchmark OSC 7-decyl-2-phenyl[1]benzothieno[3,2-b][1]benzothiophene (Ph-BTBT-10) and blends of this material with polystyrene (PS), poly(pentafluorostyrene) (PFS) and poly(methyl methacrylate) (PMMA). We show that the nature of the binding polymer has a significant impact on the device performance. The OFETs showing the best performance are the ones based on blends of PS since they reveal less interfacial traps, leading to devices with higher mobility, threshold voltage close to zero and high bias stress stability. The lowest OFET performance is found in the devices based on PMMA blends due to the higher density of majority charge carrier (*i.e.*, holes) traps. On the other hand, regarding the response of the devices to UV light, the PFS and pristine films exhibited the highest photoresponse, which was attributed to the higher density of minority charge carrier (*i.e.*, electrons) traps. Therefore, this work demonstrates that the binding polymer is a useful tool to optimise the OFET electrical characteristics as well as its photoresponsivity.

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10th Anniversary Statement

The *Journal of Materials Chemistry* and, subsequently, the *Journal of Materials Chemistry C*, has always been one of our priority journals in our research group to publish our latest results on the preparation of new materials and devices as well as on their electrical characterization. This journal has a good balance of work reporting fundamental studies, such as structure–property correlation studies, that are combined with more applied investigations. We also had the chance to contribute with several Highlight papers, which we believe provide an overview of current recent research tendencies in materials science in a concise way.

Introduction

The development of printing techniques compatible with roll-to-roll processes to deposit organic semiconductors (OSCs) is key for the progress and implementation of organic electronic devices, such as organic field-effect transistors (OFETs).^{1–4} Small molecule OSCs can be easily purified and can form more ordered crystalline thin films than polymers. However, the preparation of homogenous thin films of small molecule OSCs

employing printing techniques can be challenging due to the limited solubility of these materials, their poor stability under ambient conditions and dewetting problems caused by the low viscosity of their solutions.^{5–8} This can be mainly circumvented by blending the OSCs with insulating binding polymers.^{9,10} The use of blends has been shown to enhance the thin film processability, crystallinity and environmental stability.^{9,11–14} In addition, the use of binding polymers can provide an additional tool to tune the device properties.^{15,16} In fact, binding polymers have been exploited to control the diffusion of dopants, stabilise metastable polymorphs and reduce interfacial traps.^{17–20}

Wide ranging opportunities for OFETs are open in sensing applications since they can provide a multi-parametric electric response to physical or chemical changes in the environment with high sensitivity. In particular, OFETs are promising platforms for developing light detectors (*i.e.*, phototransistors). Photodetectors convert light into an electrical signal and have

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relevant technological applications in biomedical imaging, sensing, optical communication and environmental monitoring.^{21–24} The use of OFETs as photodetectors offers the possibility of detection wavelength tuneability, low-cost manufacturing, and compatibility with flexible substrates.^{25–27} For instance, photodetectors with high sensitivity in the UV range but negligible response in the visible range are desired in applications such as health care, chemical and pollutant sensing, combustion and flame detection, military applications and radiation detection.²⁸ Traditional UV detectors often require filters or waveguides to separate UV from visible light, increasing the device complexity.²⁹ Hence, OSCs that only absorb in the UV region can represent an appealing low-cost alternative for some applications.

When an incident photon is absorbed by the OSC an exciton is created and it diffuses through the OSC until it reaches a trap (*i.e.*, localised electronic state in the OSC band gap created by chemical impurities, structural disorder, interfacial or environmental effects, *etc.*)²⁹ that dissociates it into an electron and a hole. By trapping and de-trapping the minority or majority charge carriers, the recombination rate is reduced, increasing one kind of carrier concentration.³⁰ This can lead to an increase in the phototransistor current and a shift of the threshold voltage. Charges can be trapped at intrinsic defects at the semiconductor channel or at the OSC/dielectric interface.²⁵ Therefore, it is possible to manipulate the charge trapping process and thus the photoresponse, by modifying the thin film morphology and interfaces.^{31–33}

In this study, we fabricated OFETs based on blends of the high performing p-type OSC 7-decyl-2-phenyl[1]benzothieno[3,2-*b*][1]benzothiophene (Ph-BTBT-10, Fig. 1) with different binding polymers and investigated the effect of these blends on the OFET performance as well as on the device photoresponsivity to UV light. Binding polymers have been employed as a tool to improve the OSC processability and to achieve more homogeneous thin films. In addition, it is known that binding polymers also have an effect on the device characteristics.^{34–37} Here, it was found that the nature of the binding polymer influences the trap density of majority and minority charge carriers. The best OFET performance is found in the blend films exhibiting a lower level

of traps, while the worst performance is encountered in the films with a higher level of majority charge carrier traps. In contrast, the optimum photoresponse is revealed by the films exhibiting a higher density of minority charge carrier traps. Therefore, this work demonstrates that the binding polymer is a useful tool to tune and optimise the device properties.

Results and discussion

The OSC Ph-BTBT-10 was selected due to the fact that it is soluble in organic solvents and, hence can be processed from solution, exhibits a high mobility and, further, in the solid state, it absorbs in the UV region of 330–390 nm (maximum at 363 nm Fig. S1a, ESI†) but is transparent in the visible region.^{38,39} Thus, this OSC is a promising OSC to detect UV light.^{40,41}

Thin films of Ph-BTBT-10 and blends of this material with polystyrene (PS), poly(pentafluorostyrene) (PFS) and poly(methyl methacrylate) (PMMA) were deposited using the bar-assisted meniscus shearing (BAMS) technique on Si/SiO₂ substrates, employing the same deposition conditions as previously reported (see the Experimental section^{10,13,42,43}). The use of binding polymers typically gives rise to a vertical phase separation, where, commonly, the OSC crystallises on top of a layer of the binding polymer. The nature of the binding polymer though can influence this phase separation and the crystallisation of the OSC at the interface. Noticeably, none of these binding polymers absorb light in the UV-Vis region above 320 nm (Fig. S1b, ESI†).

The optical polarised microscope images of the thin films revealed a polycrystalline structure with small crystal domains for all blends (Fig. S2, ESI†). In addition, the films were characterised by atomic force microscopy (AFM) (Fig. 2). All the thin films are around 20 nm thick and show a very low roughness in the range 2–6 nm (Table S1, ESI†). The nature of the binding polymer results in thin films with different morphology. In the case of PFS-based films, more incomplete molecular layers are formed and thus more terraces are observed. It should be also noticed that the crystalline domains are much smaller in the PMMA blend films in comparison with the other ones. Furthermore, steps of around 2.9 ± 0.2 and 5.9 ± 0.3 nm high are observed in all the cases, which correspond to an extended molecular monolayer and bilayer, respectively. This is indicative that the OSC is crystallising on the top part of the films, as previously observed (inset Fig. 2).^{38,42}

The films were also investigated by X-ray diffraction (XRD). All samples displayed the same XRD pattern as the one previously reported for Ph-BTBT-10 films, which corresponds to a herringbone packing (Fig. S3, ESI†).^{38,42,44} Only the (00*l*) reflections are discernible, indicating that the molecules are preferentially oriented with the *ab* plane parallel to the substrate. Comparing the position of the first (00*l*) peak, small shifts can be distinguished, which might be indicative of some lattice strain caused by different binding polymers.^{45,46}

The OSC thin films were investigated as an active layer in OFETs, in a bottom gate bottom contact structure, with the aim



Fig. 1 Chemical structures of the employed small molecule organic semiconductor (top) and the binding polymers (bottom).



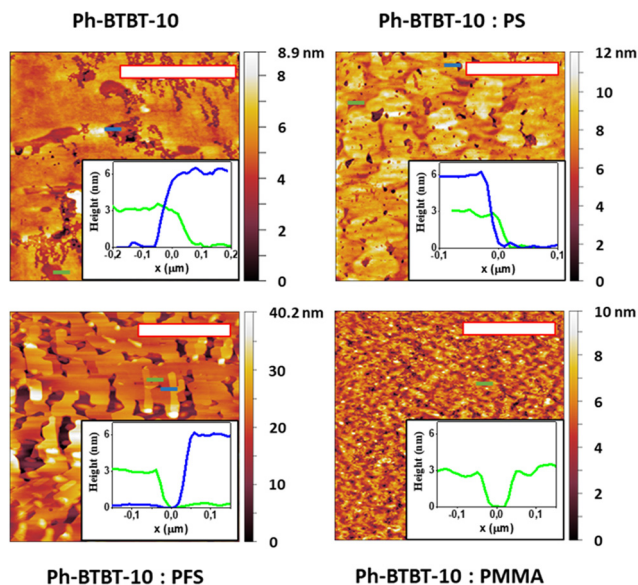


Fig. 2 AFM topography images of thin films of Ph-BTBT-10 and Ph-BTBT-10 blended with PS, PFS and PMMA, deposited by BAMS. The inset corresponds to the height profiles along the blue and green lines highlighted in the images. The blue and green lines are attributed to molecular bilayer and monolayer structures, respectively. Scale bar: 2 μm .

of exploring how the binder polymer affects their electrical performance (see Fig. 3a for the device configuration). The transfer characteristics for all the devices in the saturation regime are shown in Fig. 3b–e (see Fig. S4 for the output characteristics, ESI^\dagger), and the parameters extracted are collected in Table 1.

The devices exhibit p-type OFET behaviour. The transfer characteristics show lower hysteresis when the OSC is blended with PS and PFS compared to the devices based on only the pristine OSC. However, the OFETs based on Ph-BTBT-10 blended with PMMA clearly reveal an enhanced hysteresis, which can be caused by the hole trapping effect of the polar ester groups of this polymer.^{47–49} The devices based on blends of PS show average threshold voltage values (V_{th}) close to zero, while the ones based on the pristine OSC and blends of PFS show values slightly positively shifted (+2 V) and the blends with PMMA show higher negative V_{th} values (*i.e.*, –7 V). Positive V_{th} values are indicative of some unintentional doping, which can be caused by water from the environment in the case of pristine films and it has also been previously observed in blends based on fluorinated polymers due to p-doping of the OSC caused by the strong dipole moments of C–F bonds.^{46,50} On the other hand, the negative V_{th} value found in the PMMA blend is attributed to charge trapping at the interface, which hinders the switching on of the OFET. Finally, PS blends give rise to devices less doped and with lower interfacial traps, as previously observed with a variety of OSCs, which was ascribed to the passivation of the SiO_2 dielectric that prevents water penetration.^{12,13,17,21,51} Indeed, the interfacial hole trap densities (N_{t}) have been estimated from the sub-threshold swing (SS). In agreement with the previous observations, PMMA films exhibit the higher density of hole-traps, while the PS films the lowest one (Table 1).

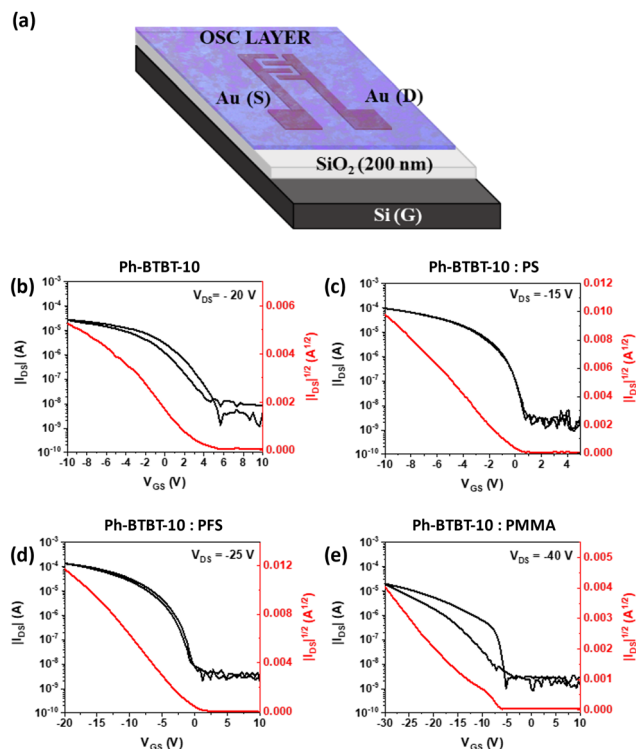


Fig. 3 (a) Schematic illustration of the OFET architecture. Transfer characteristics in the saturation regime of the OFETs based on Ph-BTBT-10 (b), and Ph-BTBT-10 blended with PS (c), PFS (d) and PMMA (e).

Taking into account the field effect mobility, the highest value is found with the PS blend with an average mobility of $1.2 \pm 0.1 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$. The pristine and PFS blends achieve mobility values of 0.33 ± 0.08 and $0.41 \pm 0.10 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, respectively. Finally, the PMMA blends show the lowest mobility (*i.e.*, $0.10 \pm 0.05 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$), which can be partly due to the lower size of the crystalline domains and the higher hole trap density. It should also be noticed that often the films based on PMMA show a double slope in the mobility extraction. In previous works, the use of PMMA in similar films gave analogous results (*i.e.*, films with lower crystal domains and reduced performance).⁴⁹

The operational stability of the OFETs was explored in a dark and ambient atmosphere ($50 \pm 5\%$ humidity). The bias stress stability in OFETs is determined by the interfacial traps but also by other factors such as the grain sizes (*i.e.*, the thin film morphology).^{52,53} The bias stress tests consisted in the application of a drain voltage $V_{\text{DS}} = -1 \text{ V}$ and gate voltages (V_{GS}) giving similar source-drain current (I_{DS}) (pristine: $V_{\text{GS}} = -7 \text{ V}$; PS blend: $V_{\text{GS}} = -2 \text{ V}$; PFS blend: $V_{\text{GS}} = -5 \text{ V}$; PMMA blend: $V_{\text{GS}} = -9 \text{ V}$), and measuring the transfer characteristics in the linear regime ($V_{\text{DS}} = -1 \text{ V}$) every 10 minutes for 3 hours (Fig. 4). Clearly, it is observed that the most operationally stable device is the one based on the PS blend, where the recorded transfer curves are almost overlapping. In contrast, in the pristine films and in the other blends a significant shift of V_{th} is taking place during the test.



Table 1 OFET electrical characteristics, bias stress fitting parameters and photoresponsivity of the OFETs prepared using the pristine Ph-BTBT-10 film and Ph-BTBT-10 films blended with PS, PFS and PMMA

Ink formulation	Pristine	PS	PFS	PMMA
Mobility ($\text{cm}^2 \text{V}^{-1} \text{s}^{-1}$)	0.33 ± 0.08	1.2 ± 0.1	0.41 ± 0.10	0.10 ± 0.05
Threshold Voltage (V)	2 ± 1	-0.2 ± 0.9	2 ± 2	-7 ± 1
$Nt(\text{eV}^{-1} \text{cm}^2)$	$(2.5 \pm 0.4) \times 10^{12}$	$(9.3 \pm 0.7) \times 10^{11}$	$(1.9 \pm 0.6) \times 10^{12}$	$(4.1 \pm 0.9) \times 10^{12}$
β	0.61 ± 0.01	0.55 ± 0.01	0.74 ± 0.02	0.78 ± 0.02
τ (s)	$(3.6 \pm 0.1) \times 10^3$	$(1.9 \pm 0.1) \times 10^4$	$(4.5 \pm 0.1) \times 10^3$	$(7.9 \pm 0.1) \times 10^3$
Photoresponsivity (mA W^{-1}) ^a	$(3.2 \pm 0.3) \times 10^2$	$(2.0 \pm 0.4) \times 10$	$(3.9 \pm 0.3) \times 10^2$	$(3.7 \pm 0.9) \times 10$

^a The photoresponsivity measurements were carried out under a light power of $486 \mu\text{W cm}^{-2}$ and an active area of $2.5 \times 10^{-3} \text{cm}^2$. The photocurrent value was extracted at $V_{\text{DS}} = -1 \text{V}$ and at $V_{\text{GS}} = V_{\text{ON}}$ of the device without UV exposure. The OFET parameters are averaged from 20 different devices, while the photoresponse parameters correspond to the average of 3 devices.



Fig. 4 Bias stress stability measurements performed by applying $V_{\text{DS}} = -1 \text{V}$ and gate voltages giving a similar source-drain current. Transfer characteristics ($V_{\text{DS}} = -1 \text{V}$) were measured every 10 min for 3 hours: (a) pristine film ($V_{\text{GS}} = -7 \text{V}$), (b) PS blend ($V_{\text{GS}} = -2 \text{V}$), (c) PFS blend ($V_{\text{GS}} = -5 \text{V}$) and (d) PMMA blend ($V_{\text{GS}} = -9 \text{V}$). Time evolution of the maximum source-drain current (e) and threshold voltage values (f) during the bias stress tests.

The I_{DS} decay caused by the bias stress was fitted with the following eqn (1), which relates the I_{DS} decay with the concentration of traps:^{54–56}

$$I_{\text{DS}}(t) = I_{\text{DS}}(0) \left(\frac{t}{\tau} \right)^{\beta} \quad (1)$$

where t is the time, τ is the relaxation time for charge trapping, and β is the dispersion parameter related to the characteristic width of the band tail of the semiconductor. The values of the

fitting parameters are shown in Table 1. The largest β values and the lowest τ were found in the PMMA blends, while the OFETs based on the PS blends exhibited the most optimum parameters, as evidenced from the observed overlapping transfer curves in the bias stress experiments. These results are in agreement with the tendency observed in the estimation of density of interfacial hole traps.

Subsequently, the electrical photoresponse of the devices under UV light was measured. A UV LED with a spectral output centred at 375 nm, close to the maximum of Ph-BTBT-10 absorbance, was employed as the light source, which was calibrated using a power meter to determine light intensity (Fig. S5, ESI[†]). In Fig. 5 the transfer characteristic plots of the devices before and upon exposition to the UV light are shown. Furthermore, the recovery curves after the light exposition are also plotted in the same figure.

It can be observed that a large increase in the off current and a significant shift of the V_{th} towards positive values is observed in the pristine and PFS blend films.^{57–60} This implies an enhancement in the majority of charge carriers (*i.e.*, holes).^{25,59} Notice that the leakage gate current under illumination is two orders of magnitude lower (Fig. S6, ESI[†]). In the films based on PMMA and PS this phenomenon is much less pronounced. In addition, in these latter films the transfer characteristics recover their initial source-drain current values quickly after irradiation, which does not occur in the pristine and PFS blend devices.

The photoresponsivity (R), defined as the photocurrent ($I_{\text{light}} - I_{\text{dark}}$) generated by unit of optical power density of the incident light (P) (eqn (2)), was calculated for all the films (Table 1).

$$R = \frac{I_{\text{light}} - I_{\text{dark}}}{P} \quad (2)$$

The highest photoresponse was found for the Ph-BTBT-10 ($P = (3.2 \pm 3) \times 10^2 \text{mA W}^{-1}$) and Ph-BTBT-10:PFS films ($P = (3.9 \pm 3) \times 10^2 \text{mA W}^{-1}$). These values were two orders of magnitude higher than the one found for the PMMA-based films, while the PS blends showed an intermediate response. In the case of the pristine films, the hydroxyl groups of the SiO_2 dielectric are known to act as electron traps.⁶¹ Regarding the PFS blends, the effect of the dipole groups could also lead to electron trapping.^{50,62,63} Thus, the interfacial electron trap density induced by the PFS binder polymer or the SiO_2 interface



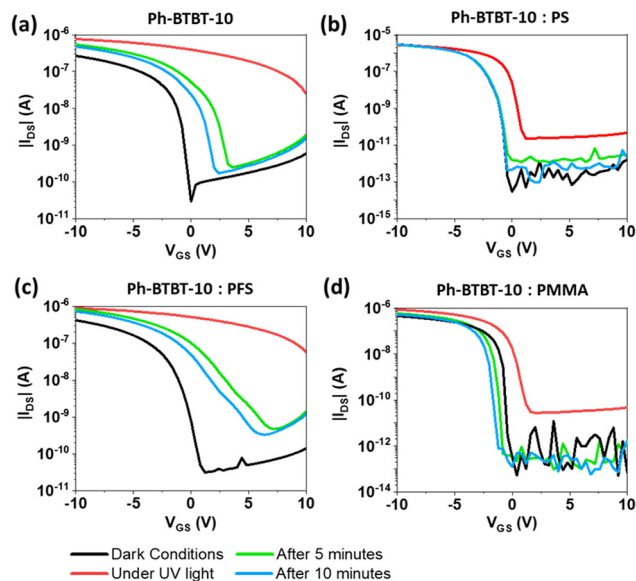


Fig. 5 Transfer characteristics curves ($V_{DS} = -1$ V) before UV exposition, under UV light and after 5 and 10 minutes of the UV light exposition for (a) pristine Ph-BTBT-10 films and Ph-BTBT-10 blend films with (b) PS, (c) PFS and (d) PMMA. The measurements were carried out under a light power of $486 \mu\text{W cm}^{-2}$.

boosts the photoresponse of the OFETs. This is due to the fact that when the generated excitons are dissociated, the electrons are trapped, reducing the hole–electron recombination and increasing the measured hole source–drain current. In contrast, the lower response of the PMMA films can be explained by the fact that, as previously mentioned, the ester groups of the polymer act as trapping sites for holes and, therefore, the increase of measured current is less noticeable.³³

The dynamic photoresponse of all the prepared OFETs was evaluated by monitoring the I_{DS} as a function of time under three different powers of UV illumination (210 , 486 and $790 \mu\text{W cm}^{-2}$). Fig. 6a shows the dynamic photoresponse behaviour for a short illumination pulse time of 5 s with recovery periods of also 5 s. Notice that in these measurements the devices were in the ON state: V_{DS} was kept at -1 V and, in order to have a similar initial I_{DS} (*i.e.*, $1 \mu\text{A}$), the applied V_{GS} for the pristine, PS, PFS and PMMA blends were -4.5 , -1 , -0.7 and -11 V, respectively. In all the cases, after illumination an increase in I_{DS} is observed, which tends to recover when the light is switched off. As expected, the increase in current is greater when more power light is applied. It is observed that with time the PMMA films respond less to light. This is more clearly visualised when performing longer light pulses (110 s of light exposition and recovery), as shown in Fig. 6b. Therefore, it is demonstrated that the PMMA blends not only show a lower photoresponse but they also exhibit a very poor photostability.

Experimental section

Materials

Ph-BTBT-10 was purchased from TCI chemicals, PMMA ($25\,000 \text{ g mol}^{-1}$) from Polysciences, Inc., and PS (M_w $280\,000 \text{ g mol}^{-1}$), PFS

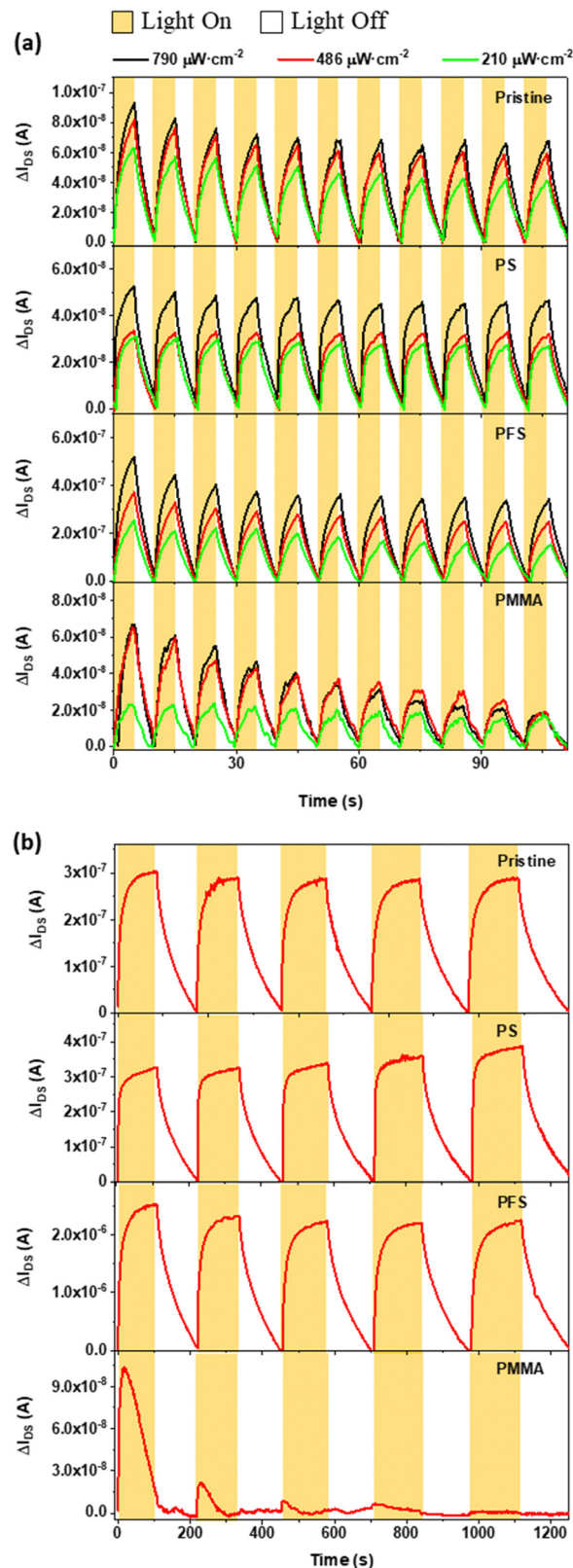


Fig. 6 Plots of photocurrent versus time of pristine, PS, PFS and PMMA-based films (a) LED light with $\lambda = 370$ nm and three different powers (*i.e.*, 790 , 486 and $210 \mu\text{W cm}^{-2}$). The time interval between switching the light on and off is 5 s. (b) Light intensity fixed at $486 \mu\text{W cm}^{-2}$ and the light on/off time interval is 110 s. It is noted that the active area was $2.5 \times 10^{-3} \text{ cm}^2$. In all the experiments, $V_{DS} = -1$ V and V_{GS} were applied to reach an initial I_{DS} of $1 \mu\text{A}$.



(polydisperse), 2,3,4,5,6-pentafluorothiophenol (PFBT, 97%) and *o*-xylene ($\geq 99.5\%$) were purchased from Sigma-Aldrich. All the materials were used as received.

Device fabrication

Interdigitated evaporated source and drain electrodes (Cr (5 nm) and Au (40 nm)) were fabricated by photolithography on a heavily n-doped Si wafer (Si-Mat) with a 200 nm oxide layer. The channel length and width were fixed at 50 μm and 5000 μm , respectively. The substrates were cleaned in an ultrasonic bath with acetone and isopropanol and then dried under nitrogen flow. The gold surface of the source and drain electrodes was then chemically modified with a self-assembled monolayer of PFBT. The substrates were first cleaned using ultraviolet ozone for 25 min, and were then immersed in a 10^{-3} M solution of PFBT in isopropanol for 15 minutes. Afterwards, the substrates were rinsed with isopropanol and dried with nitrogen.

Pristine Ph-BTBT-10 and blend solutions of Ph-BTBT-10 with PMMA, PFS and PS at a weight ratio of 2 : 1 were dissolved in *o*-xylene (2.5 wt%). Previously to their deposition, all solutions were heated at 105 $^{\circ}\text{C}$. The active layers were deposited on the substrates using the BAMS technique at 10 mm s^{-1} and at a substrate temperature of 105 $^{\circ}\text{C}$, using home-designed equipment.^{10,13,19,42} Note that all the fabrication process was carried out under ambient conditions and no post-thermal treatments were required.

Electrical measurements

The electrical measurements were performed under ambient conditions using an Agilent B1500A semiconductor devices analyser connected to the samples with a Karl Suss probe station. The UV light system was a home-made setup with an UV LED (LED370E from ThorLabs) with a spectra intensity distribution centred at $\lambda = 370$ nm (power information shown in the ESI† Fig. S4). An opaque box to shade the ambient light was used. Transfer characteristics were measured in the saturation regime. The mobility and threshold voltage were extracted in the saturation regime using eqn (3):

$$I_{\text{DS}} = \frac{W}{2L} \mu C (V_{\text{GS}} - V_{\text{th}})^2 \quad (3)$$

where C is the insulator capacitance per unit area ($C = 17.26$ nF cm^{-2}) and W and L are the width and length of the channel, respectively.

The interfacial trap density per unit area (N_T) was estimated using the relationship (eqn (4)):

$$N_T = \frac{C}{q} \left[\frac{q \cdot \text{SS}}{k_B T \ln(10)} - 1 \right] \quad (4)$$

where SS is the sub-threshold swing, q is the electronic charge, k_B is the Boltzmann constant, and T is the absolute temperature.

Thin-film characterisation

Optical microscope images were taken using an Olympus BX51 equipped with a polariser and analyser. X-ray diffraction

measurements were carried out with a Siemens D-50 000 diffractometer. The Cu K radiation used was 1.54187 \AA . Atomic Force Microscopy (AFM) images were taken with a 5100 and 5500LS SPM system from Agilent Technologies. Surface topography and film thickness were examined using a 5500LS SPM system from Agilent Technologies and subsequent data analysis was performed by using Gwyddion 2.61 software. The absorption spectrum of the polymer solutions and the OSC thin films prepared on quartz substrates were measured using a UV-visible Jasco spectrophotometer (V-780) on films.

Conclusions

In summary, in this work we fabricated thin films of the OSC Ph-BTBT-10 and blends of this material with three different binding polymers: PS, PFS and PMMA. The Ph-BTBT-10 OSC was selected since it exhibits a high hole mobility, it can be processed from solution and is absorbed in the UV region, thus being a promising material for the development of UV-photodetectors.

It was observed that the nature of the binding polymer has a dramatic effect on the electrical OFET properties. The films based on PS exhibited the best performance, showing the highest mobility, a V_{th} close to zero, a low level of interfacial traps and a high bias stress stability. In contrast, the PMMA blends showed the poorest performance, which was mainly attributed to the higher level of interfacial hole traps (*i.e.*, majority carriers). Taking into account the UV photoresponse, a different scenario was encountered. In this case, the pristine films and the PFS blend films exhibited the highest response. This was explained by the higher density of electron traps (*i.e.*, minority carriers), which promoted a larger increase in the measured hole current after exciton generation and dissociation. On balance, the devices based on the Ph-BTBT-10:PFS blend showed the most promising electrical performance with an optimum UV-light photoresponse.

All in all, this work demonstrates that the use of binding insulating polymers provides an additional and highly valuable tool to tune and optimise the device electrical response.

Conflicts of interest

There are no conflicts to declare.

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